



00684.002846

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)		
KAZUNORI IWAMOTO, ET AL.		:	Examiner: P.S. Natividad Group Art Unit: 2877	
Application No.: 09/323,034)	Gloup Art Ollic. 2011	
Filed:	June 1, 1999	:)		
For:	SCANNING EXPOSURE METHO AND APPARATUS, AND DEVIC MANUFACTURING METHOD USING THE SAME	•	June 26, 2002	TC 28
The Commissioner for Patents Washington, D.C. 20231				£00 t

AMENDMENT

Sir:

In response to the Office Action mailed March 26, 2002, the Examiner is respectfully requested to consider and enter the following amendments:

IN THE ABSTRACT:

Please rewrite the Abstract of the Disclosure as follows:

to a scan direction, and in an X direction intersecting the scan direction, an alignment scope for

--A scan type exposure for transferring a pattern onto a substrate by scan exposure. The apparatus includes a stage for moving the substrate in a Y direction corresponding

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